

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No. 253/006

In re Application of

Jung-Ho LEE, et al.

Serial No.: 09 686,624

Filed: October 12, 2000

Group Art Unit: 2823

For: SPIN-ON GLASS COMPOSITION AND METHOD OF FORMING SILICON OXIDE LAYER, etc.

TRANSMITTAL

Commissioner for Patents
Washington, D.C. 20231

Sir:

Transmitted herewith is an Amendment in the above-captioned application. The fee has been calculated as shown below. *(Small entity fees indicated in parentheses.)*

CLAIMS AS AMENDED						
1	2	3	4	5	6	(7)
	Claims Remaining After Amendment		Highest Number Previously Paid For	Extra Claims	Rate	Fee
Total Claims	18		37		18.00	0.00
Small Entity					9.00	
Independent claims	5		3	2	84.00	168.00
Small Entity					42.00	
Multiple Dependent					280.00	0.00
Small Entity					140.00	
Extension of Time	One Month	Two Months	Three Months			0.00
Fee	\$110	\$400	\$920			
Small Entity	(\$55)	(\$200)	(\$460)			
Total						\$168.00

The Commissioner is hereby authorized to charge any fees associated with this filing to our Deposit Account No. 5-01645.

Respectfully submitted,
LEE & STERBA, P.C.

Date: October 8, 2002

Eugene M. Lee
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8/11/02
10/11/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :)
Jung-Ho Lee, et al.) Examiner: Khiem D. Nguyen
Serial No.: 09 686,624) Group Art Unit: 2823
Filed: October 12, 2000) Attorney Docket No.: 253/006

For: SPIN-ON GLASS COMPOSITION AND METHOD
OF FORMING SILICON OXIDE LAYER IN
SEMICONDUCTOR MANUFACTURING PROCESS
USING THE SAME

Assistant Commissioner for Patents
Washington, D.C. 20231

**AMENDMENT AND REQUEST FOR RECONSIDERATION
PURSUANT TO 37 C.F.R. § 1.111**

Sir:

In response to the Office Action mailed July 9, 2002, please amend the application
as follows:

IN THE CLAIMS:

✓ Please cancel claims 1-9, 13, and 29-37.